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Simulation Of Thin Nickel Films
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*Computer Simulation Of
Thin Nickel Films On
Single Layer*

***This book describes
systematically the theory and
technology of the precision***

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forming of large, complex and thin-walled superalloy castings for aircraft engines, covering all the important basic aspects of the manufacturing process, including process design, wax pattern, ceramic molds,

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***casting and solidification,
heat treatment, repair casting
and dimension precision
control. The correlation of
casting defects, structural
characteristics and
performance of castings is
revealed through a range of***

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tests. It also discusses the latest technologies and advances in this field - such as imaging the solidification process by means of synchrotron radiography, 3D computerized tomography and reconstruction of

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***microporosity defects,
analysis and diagnosis of
error sources for dimension
over-tolerance and adjusted
pressure casting technology -
which are of particular
interest. Providing essential
insights, the book offers a***

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***valuable guide to the design
and manufacture of superalloy
casting parts for aircraft
engines.***

***Volume 6A Surfaces I
Bell Laboratories Talks and
Papers***

Solar Energy Update

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Metals Abstracts

***Investigation of the Fracture
Toughness of the Nickel-
Alumina System Interface***

This Special Issue of
Nanomaterials collects a series
of original research articles

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providing new insight into the application of computational quantum physics and chemistry in research on nanomaterials. It illustrates the extension and diversity of the field and indicates some future

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directions. It provides the reader with an overall view of the latest prospects in this fast evolving and cross-disciplinary field

BTL Talks and Papers
Physics Briefs

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A Selected Listing of NASA
Scientific and Technical Reports
for ...

Applied Mechanics Reviews
Transport in Nonstoichiometric
Compounds

Nanocrystalline nickel-tungsten

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alloys are harder, stronger, more resistant to degradation, and safer to electrodeposit than chromium. Atomistic computer simulations have previously met with success in replicating the energetic and atomic conditions of physical

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systems with 2-4nm grain diameters. Here, a new model subjects a vertically thin unique volume containing 3nm or 10nm FCC grains with aligned z axes to a Monte Carlo-type minimization to investigate the segregation and

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ordering behavior of W atoms. Short-range order is also tracked with the Warren-Cowley parameter, and energetic results are explored as well. It was found that the Ni-W system has a very strong tendency toward SRO. The

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10nm models exhibited more robust order at low concentrations, but ordering in the 3nm model was generally more pronounced. At the dilute limit atoms are driven to the grain boundaries, but as the boundaries are saturated

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Intragranular ordered formations increase and may even perpetuate over low-angle grain boundaries. Ordering was also observed within the grain boundaries at all concentrations for both diameters. The 10nm models were saturated

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at lower concentration, and grain boundary energy was reduced by up to 93%. W atoms preferred to associate with each other as third-nearest neighbors, but at very high concentrations formations with W atoms as second nearest neighbors

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were also observed.

Effects of Radiation on Materials

Vacancies and Interstitials in

Metals and Alloys

Materials Transactions

NBS Special Publication

ERDA Energy Research Abstracts

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Symposium held in Nashville, Tennessee, June 1990. Almost two-thirds of these 91 papers are authored by researchers outside of the US (including information on research in the former USSR, Japan, and Europe). Topics include: current commercial power reactor systems; microstructural characterization

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NASA Tech Briefs

Ion-solid Interactions

*Computational Quantum Physics and
Chemistry of Nanomaterials*

*U.S. Government Research &
Development Reports*

NASA SP.

Masters Theses in the Pure and Applied

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Sciences was first conceived, published, and disseminated by the Center for Information and Numerical Data Analysis and Synthesis (CINDAS) * at Purdue University in 1957, starting its coverage of theses with the academic year 1955. Beginning with Volume 13, the printing and dissemination phases of the

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activity were transferred to University Microfilms/Xerox of Ann Arbor, Michigan, with the thought that such an arrangement would be more beneficial to the academic and general scientific and technical community. After five years of this joint undertaking we had concluded that it was in the interest of all con

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cerned if the printing and distribution of the volumes were handled by an international publishing house to assure improved service and broader dissemination. Hence, starting with Volume 18, Masters Theses in the Pure and Applied Sciences has been disseminated on a worldwide basis by

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Plenum Publishing Corporation of New York, and in the same year the coverage was broadened to include Canadian universities. All back issues can also be ordered from Plenum. We have reported in Volume 28 (thesis year 1983) a total of 10,661 theses titles from 26 Canadian and 197 United States universities. We

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are sure that this broader base for these titles reported will greatly enhance the value of this important annual reference work. While Volume 28 reports theses submitted in-1983, on occasion, certain universities do report theses submitted in previous years but not reported at the time.

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Accepted by Colleges and Universities of
the United States and Canada Volume 28
Proceedings of the International
Conference on Vacancies and
Interstitials in Metals and Alloys, Held
in Berlin, Germany, September 14-19,
1986

Masters Theses in the Pure and Applied

Bookmark File PDF Computer Simulation Of Thin Nickel Films On Single Layer Sciences

Computer Literature Bibliography:
1964-1967

Scientific and Technical Aerospace
Reports

The last quarter-century has
been marked by the extremely
rapid growth of the solid-state

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sciences. They include what is now the largest subfield of physics, and the materials engineering sciences have likewise flourished. And, playing an active role throughout this vast area of

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science and engineering have been very large numbers of chemists. Yet, even though the role of chemistry in the solid-state sciences has been a vital one and the solid-state sciences have, in turn, made

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enormous contributions to chemical thought, solid-state chemistry has not been recognized by the general body of chemists as a major subfield of chemistry. Solid-state chemistry is not even

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well defined as to content. Some, for example, would have it include only the quantum chemistry of solids and would reject thermodynamics and phase equilibria; this is nonsense. Solid-state

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chemistry has many facets, and one of the purposes of this Treatise is to help define the field. Perhaps the most general characteristic of solid-state chemistry, and one which helps differentiate it from solid-state

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physics, is its focus on the chemical composition and atomic configuration of real solids and on the relationship of composition and structure to the chemical and physical properties of the solid. Real

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solids are usually extremely complex and exhibit almost infinite variety in their compositional and structural features.

JJAP

Computer Simulation and

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On Single Layer

Electron Microscopy of
Crystalline Interfaces
Monte Carlo Study of
Fluctuations and Magnetization
Reversal in Nickel-iron
Ferromagnetic Ultra-thin Films
Nuclear Science Abstracts

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Atomistic Computer Simulation
Analysis of Nanocrystalline
Nickel-tungsten Alloys
*Prior to the 9th International
Conference on Reactivity Solids in
Krakow, Poland a group of about
25 international scientists held a*

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*special conference entitled
"Transport in Nonstoichiometric
Compounds" in late Aug. 1980 in
Mogilany, Poland (near Krakow).
This conference was well received
in view of the interaction between
the participants, as well as the*

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resulting publication of the proceedings (Elsevier Scientific Publishing Company, 1982, edited by J. Nowotny). At this first conference the participants decided that it would be desirable to organize similar conferences at

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about two year intervals. Thus, a second meeting was held in late June, early July at Alenya, Pyrenees Orientales, France. This conference had a larger number of participants, about 50, but still managed to promote excellent

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interaction between all the participants. These proceedings, with editors G. Petot-Ervas, Hj. Matzke and C. Monty, have also been published by Elsevier as a special edition of the journal, Solid State Ionics, Vol. 12 (1984). In view

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of the success of the initial two conferences, a third meeting was organized and held at The Pennsylvania State University, University Park, PA., 16802, U.S.A. from 11 June 84 to 15 June 84. The proceedings of this conference are

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presented in the following text.

Metals Abstracts Index

Regular papers & short notes

ICCF8

Materials Transactions, JIM.

*Precision Forming Technology of
Large Superalloy Castings for*

Bookmark File PDF Computer Simulation Of Thin Nickel Films On Single Layer *Aircraft Engines*

This dissertation presents a Monte Carlo simulation study of fluctuations and magnetization reversal in thin (5, 10 and 20 nanometers thin), permalloy (Ni 81 Fe 19) films. The

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study shows how the presence of vertical end pinned domains (VEPDs) in these films leads to nucleation of vortices and anti-vortices. We also show how the vertical edge pinned domains (VEPDs) lead to the

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formation of horizontal edge pinned domains (HEPDs) in the course of a films magnetization reversal. A mechanism for HEPD-reversal is discovered, involving the creation and motion of a head-to-head domain wall.

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When vortices nucleate to
initiate a films
magnetization reversal the
switching field varies
linearly with temperature,
and for reversal that starts
with growth of VEPDs
switching field has a T^2

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dependence. Novel images of spin configuration are used to show fluctuations and magnetization reversal. Our thin film's easy-axis is parallel to the length of the film. For a 5 nm thin film, the author shows that

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roughness in the edges
parallel-to-the-easy-axis
increases the switching
field of the film in
comparison to the switching
field of a control film--a
similar film with straight
edges--by 3.9% in an aspect

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ratio 5 film and by 6.7% in
an aspect ratio 1.5 film.

When roughness, or etching,
is in the edges perpendicular
r-to-the-easy-axis the
switching field of such
films is less than that of
the control film by 2.8% and

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by 4.2% in the respective cases. The mechanisms described in this work are of importance in computer memory and data-storage industry, as well for sensor and circuit isolator applications.

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Technical Abstract Bulletin
15th International Symposium
Index
A Selected Listing
Energy Research Abstracts